

Czochralski Growth of Silicon Wafers

Senior Design Project
Faculty Advisor: T.R. Sinno

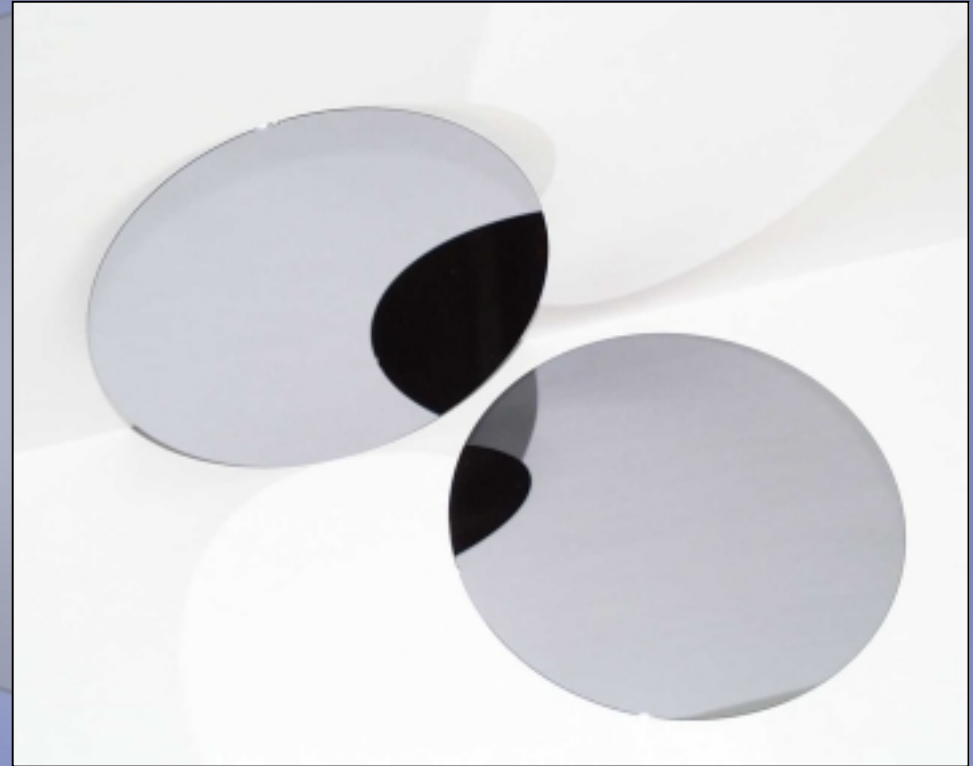
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Eiji Takizawa
Joyce Tam

Project Outline

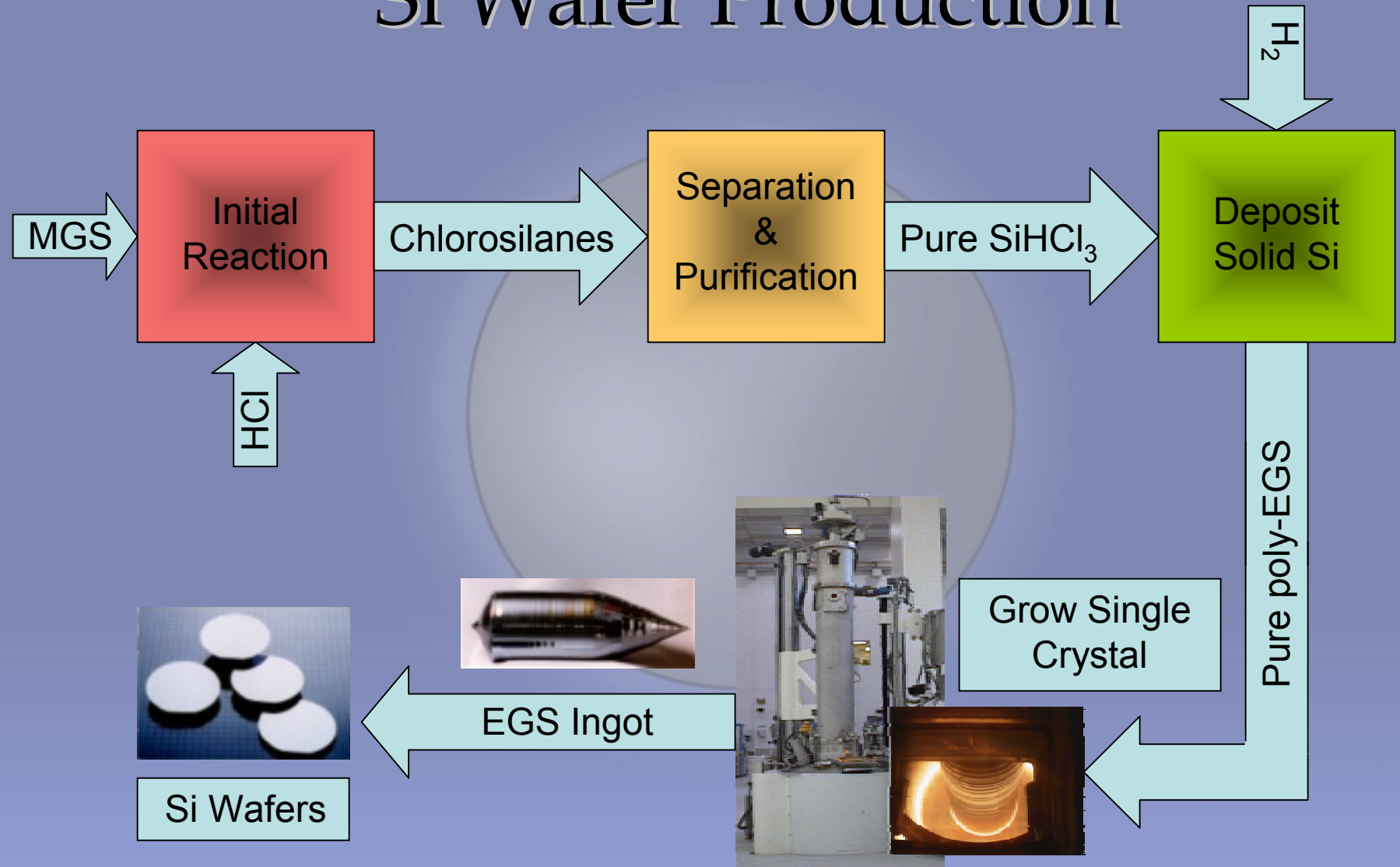
- Is it economically feasible to enter the silicon wafer market?
 - Describe a process to produce silicon wafers
 - Introduce a revolutionary method for reducing plant capital cost (batch recharge)
 - Evaluate economic feasibility of entering market using both traditional and batch recharge methods

Silicon Wafer Basics

- Wafer Diameters:
200mm or 300mm
- Wafer Thickness:
 $\sim 650\mu\text{m}$
- Wafer Purity: 150
parts/trillion
impurities
(99.999999999% Si)
- Single Crystal

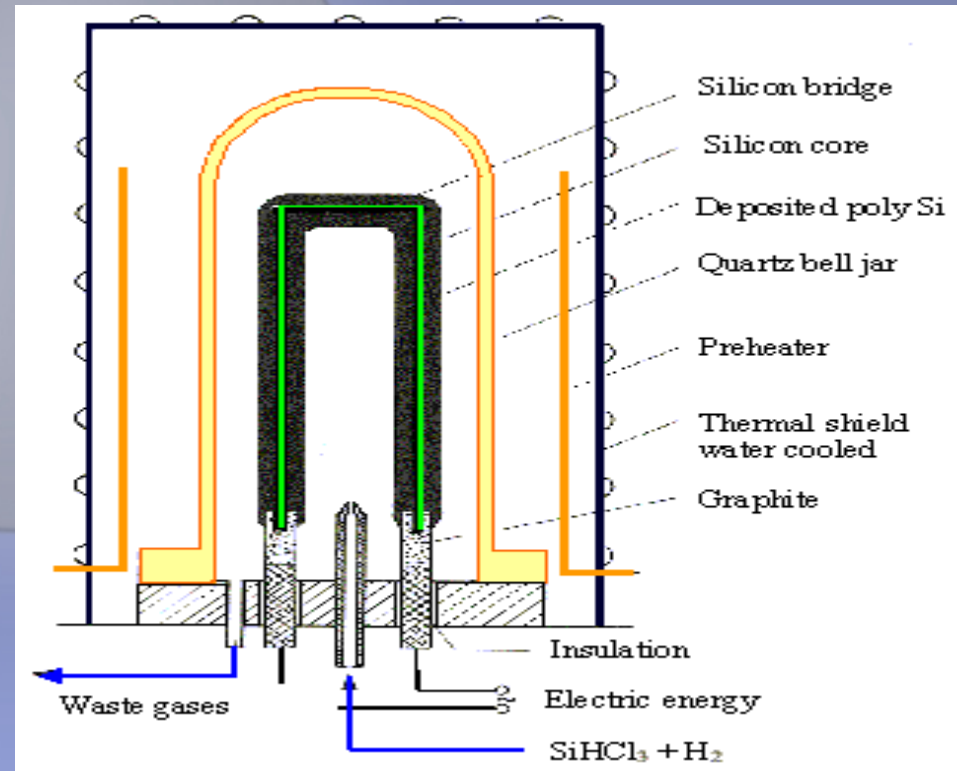


Si Wafer Production



Deposit Solid Si: Siemens Reactor

- Pure SiHCl_3 in Gas Phase \rightarrow Pure Si in Solid Phase
 - Chemical Vapor Deposition (CVD) process
 - Specific Reactor Type = Siemens Reactor
- Deposition process is slow
 - 10 days/ton
- How many Siemens reactors are required?
 - 12 Siemens reactors required

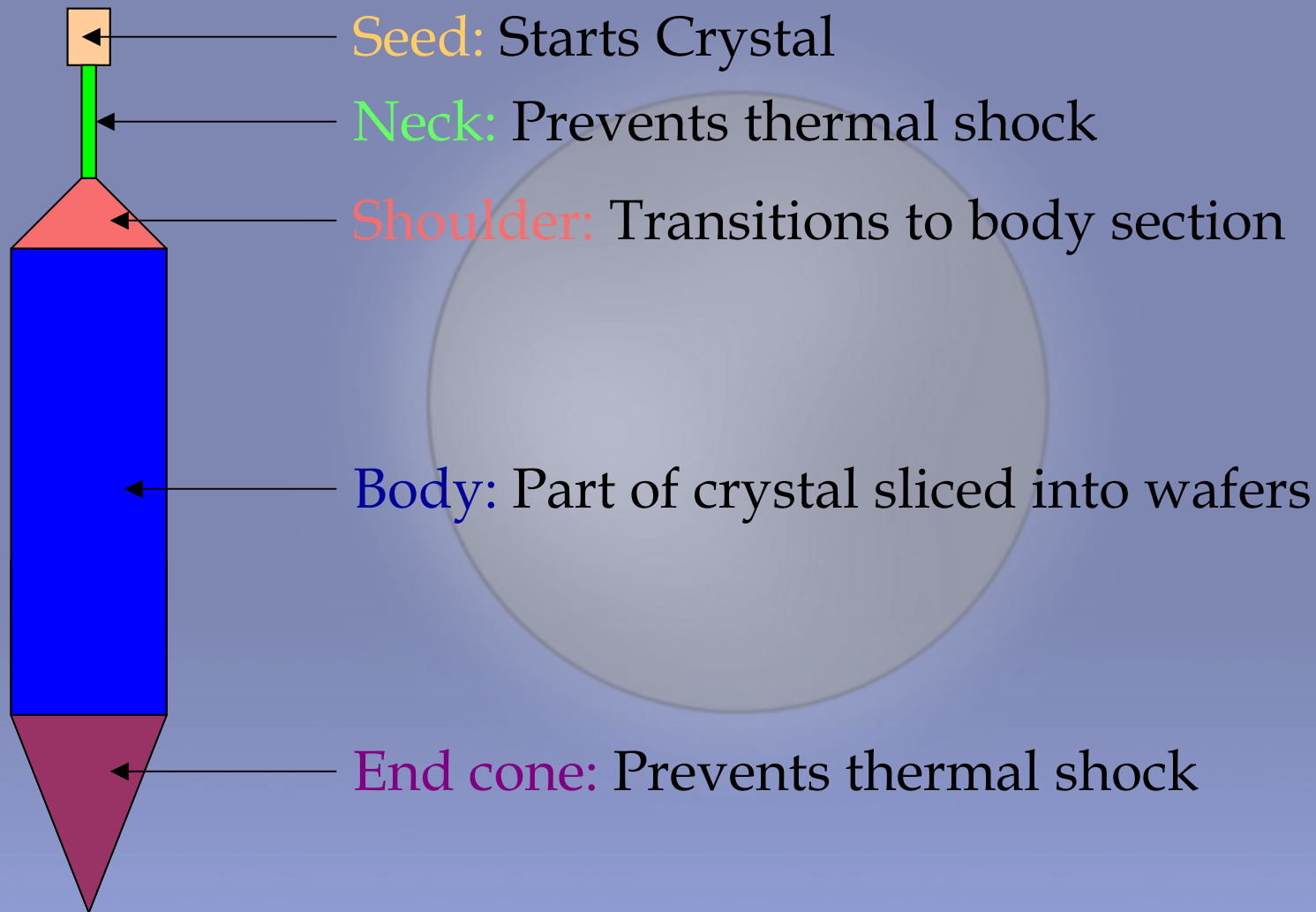


Czochralski Crystal Grower

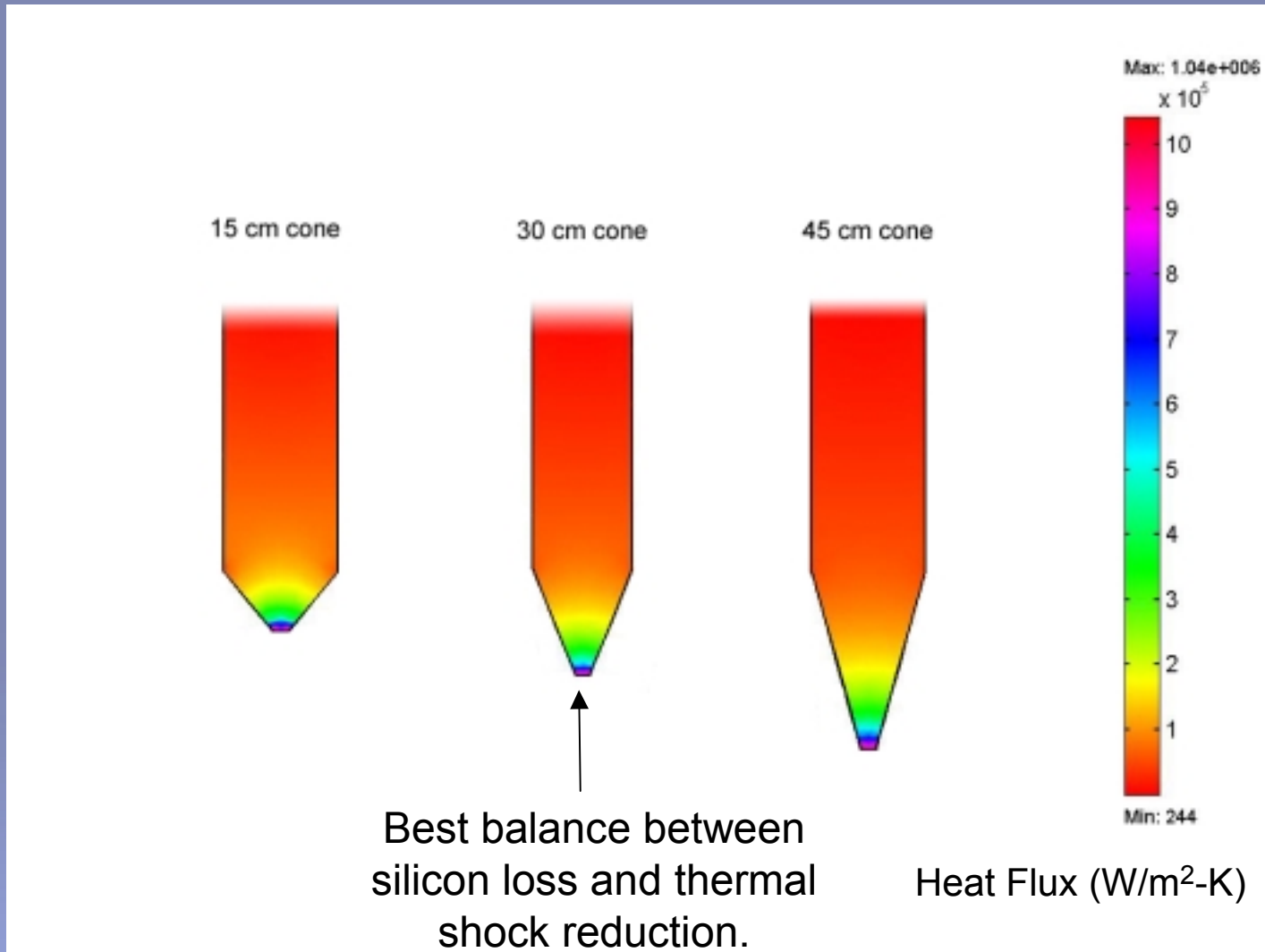
- Poly-EGS is melted in a quartz crucible (SiO_2)
- Seed particle introduced to begin crystallization
- Seed pulled to generate desired wafer diameter
- Ingot is cooled
- Crucible is discarded (warping and cracking)



Finished Crystal Parts



End Cone Femlab results



Czochralski Results

- From presented data, we can calculate:
 - Throughput/Cz grower
 - Total number of Cz growers required

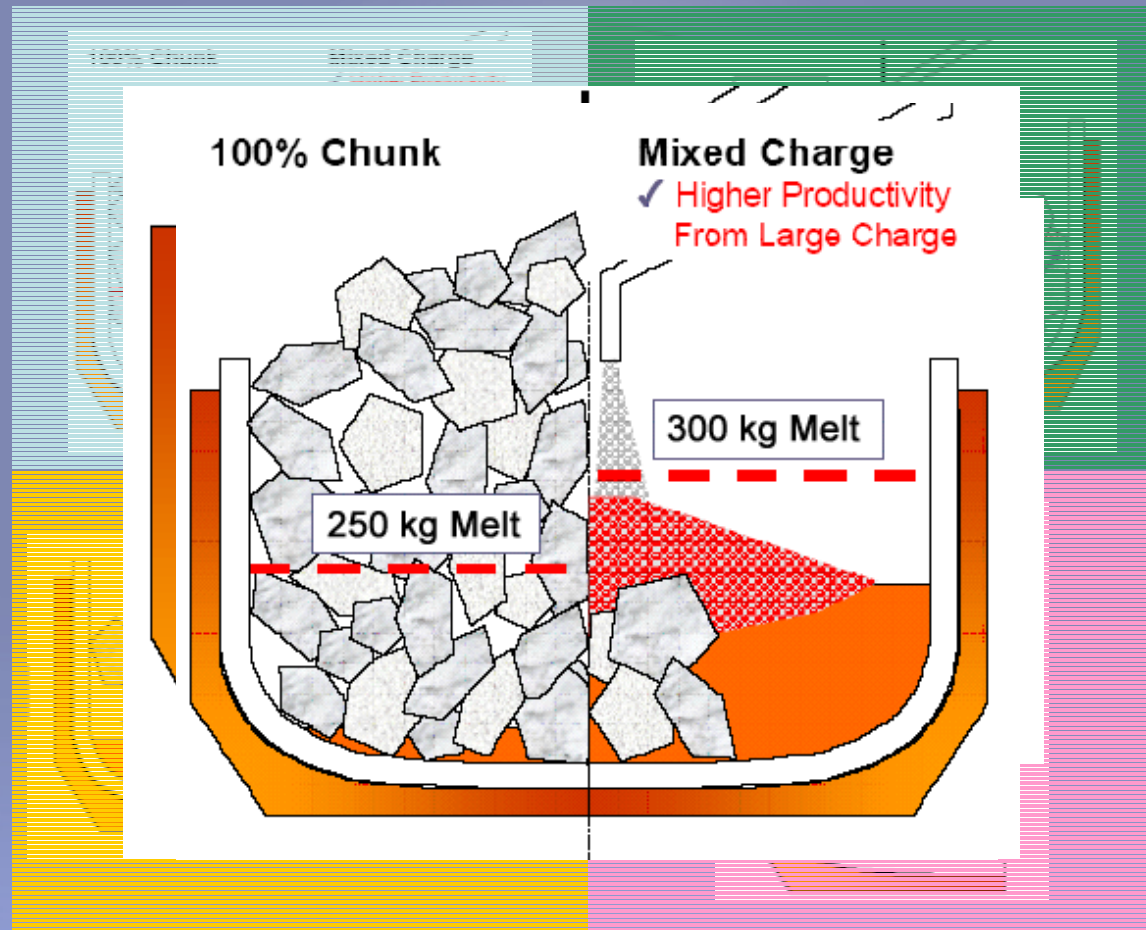
**26 Cz Growers needed to produce
100,000 wafers/month**

Batch Recharge Cz (BRCz) Method

- Czochralski grower crucible can be recharged 7 times before it is discarded.
- Recharge is done using granular silicon.
- Initial charge of crucible is mixed.

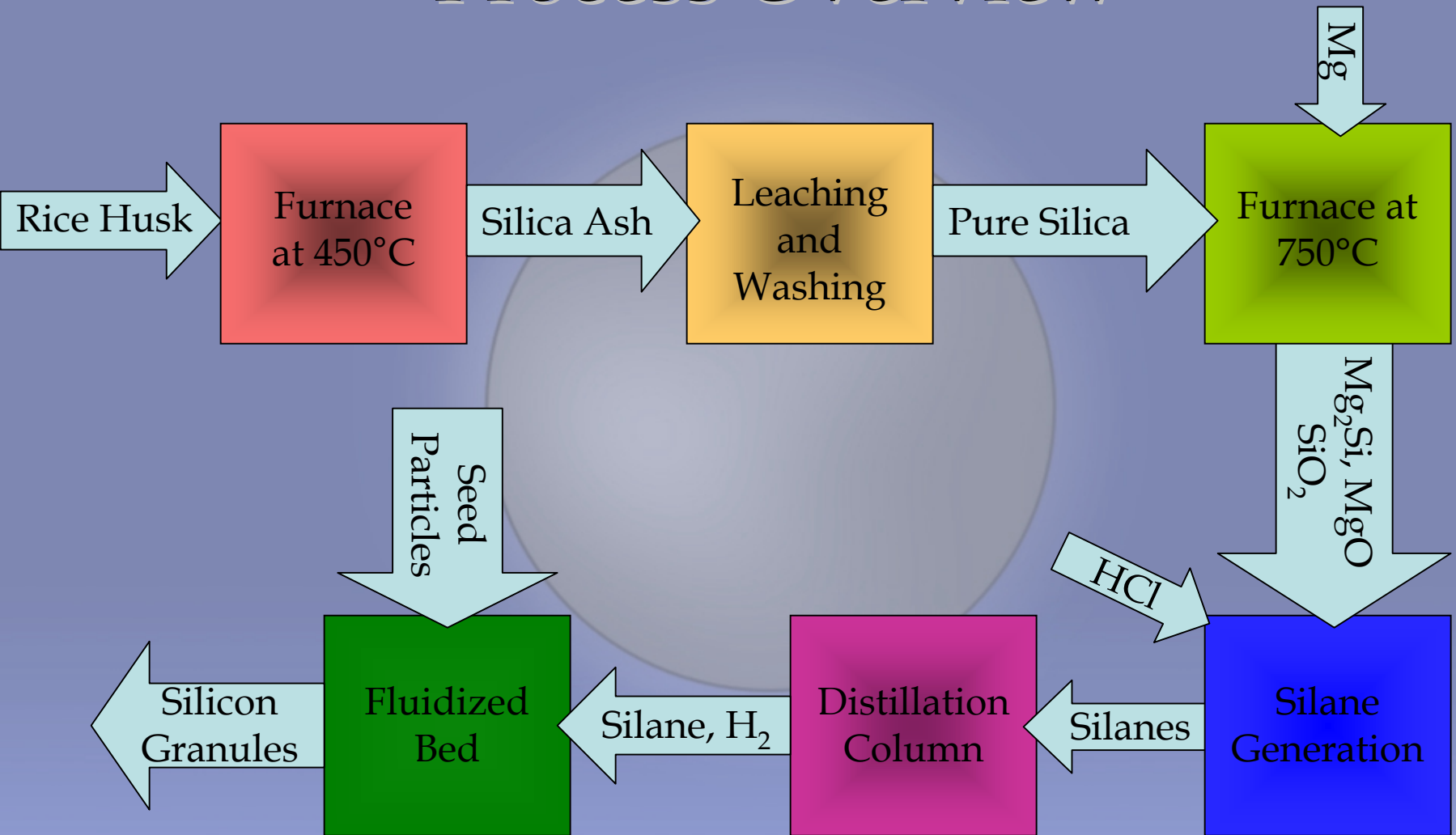


Mixed Charge vs. Chunk Charge



Figures from MEMC

Process Overview

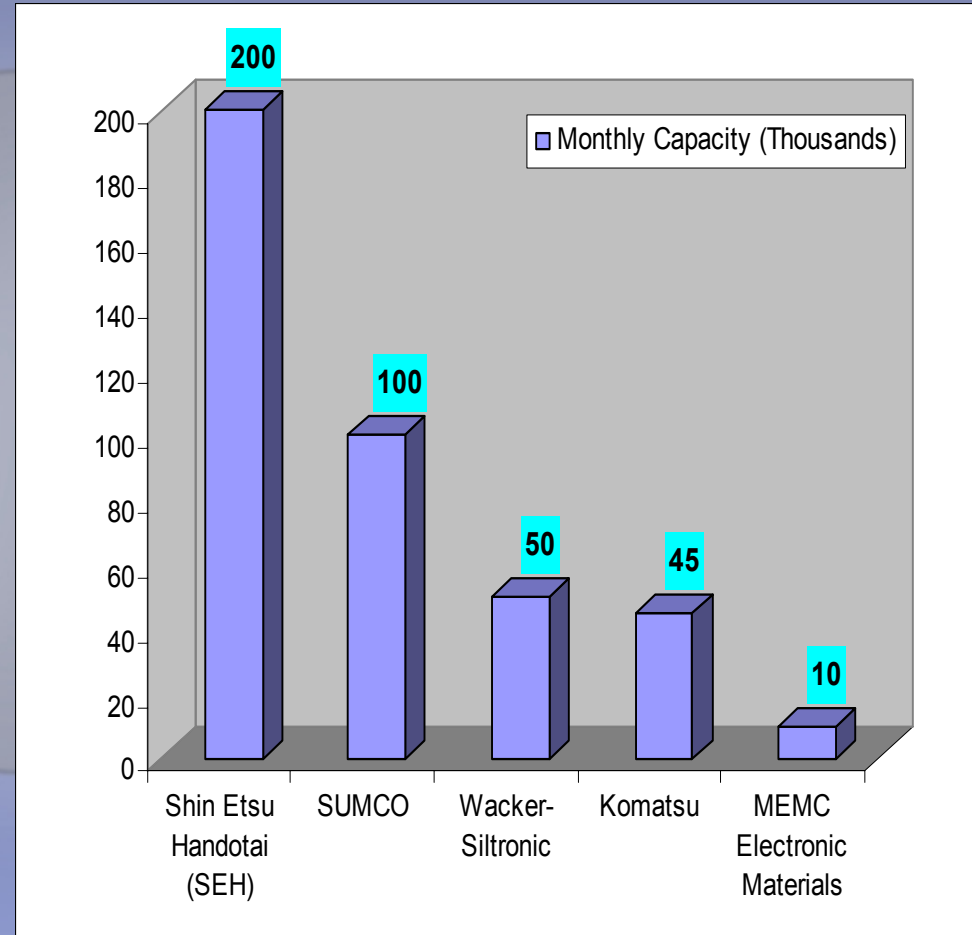


Summary of BRCz

- Benefits of Batch Recharge Cz:
 - Crucible life is extended
 - Throughput is increased (8 BRCz Growers = 9 Traditional Cz Growers)
 - Utilities are reduced
 - Larger charge size
 - Yield is improved
 - In traditional Cz, 7.5% (18.75 kg) of charge is lost as residual melt in the crucible (pot scrap).
 - $\frac{18.75}{(8)(300)} * 100 = 0.78\%$ of EGS is lost as pot scrap.
- Drawback of BRCz:
 - Need to build additional plant
 - But previous plant can be downsized

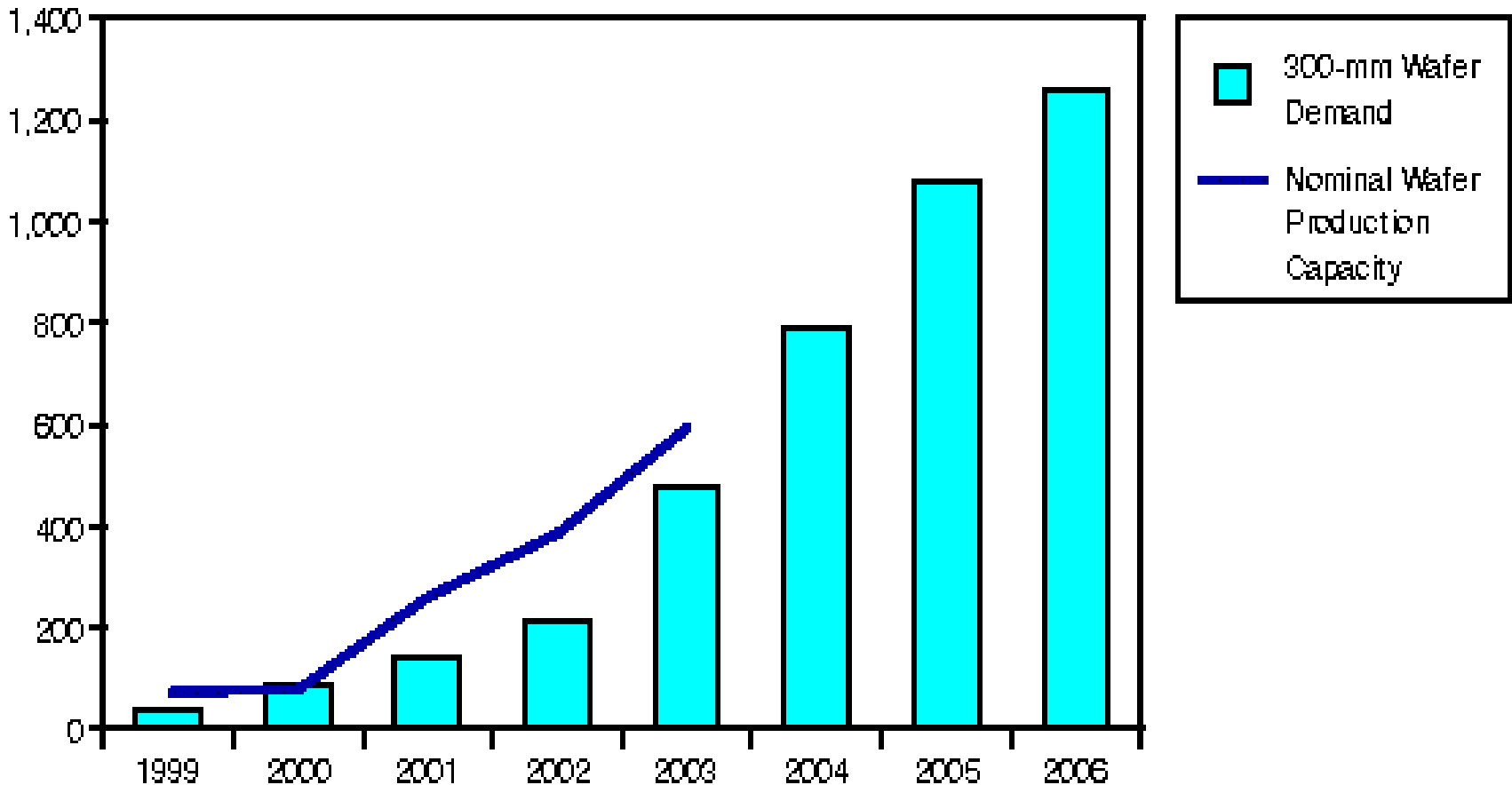
The Big Five

- The Big Five: SEH, SUMCO, Wacker-Siltronic, Komatsu, and MEMC
- 90% of world's Si wafer producers
- MEMC Expansion



Market Wafer Demand Trend

Thousands of Units per Month

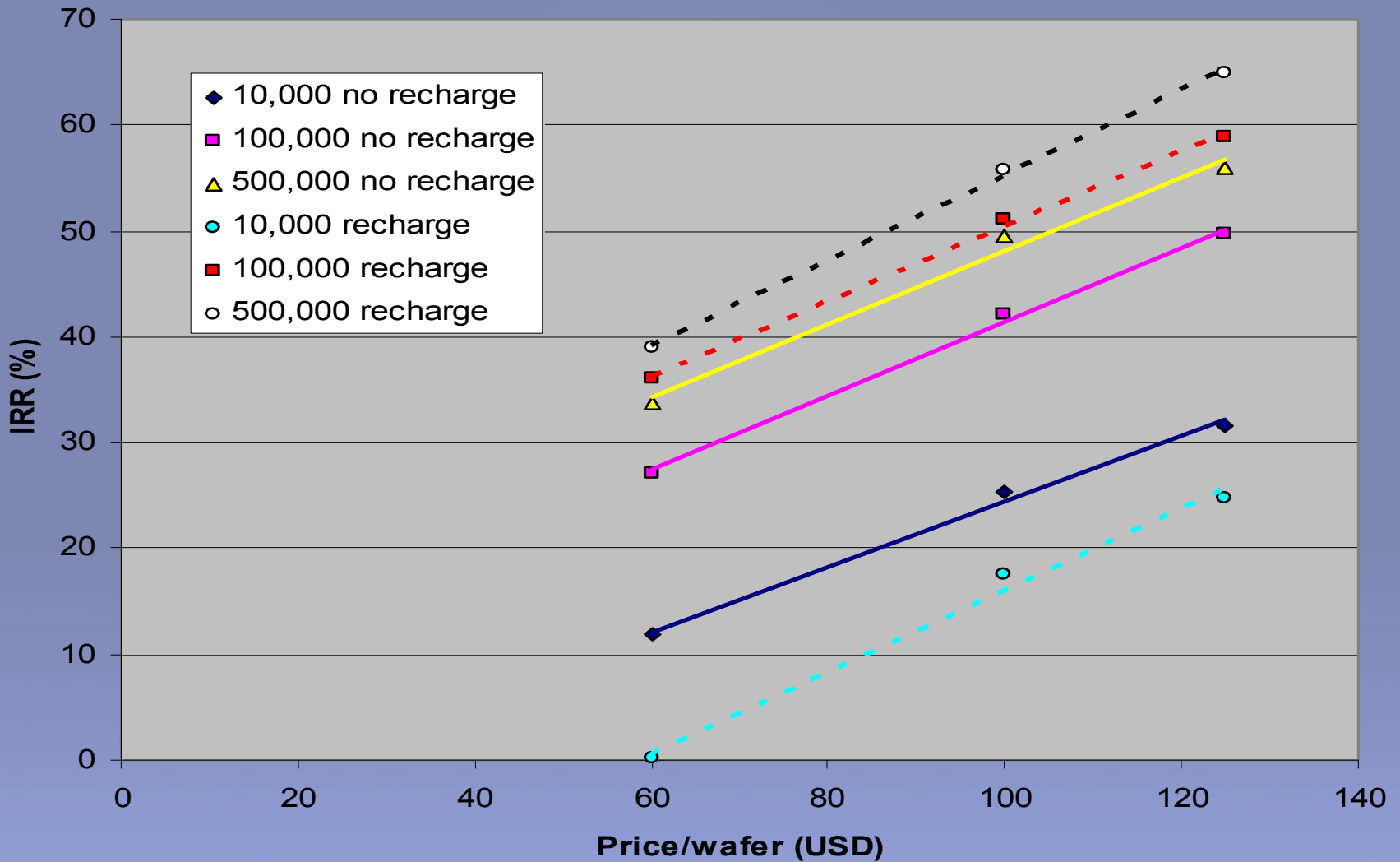


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Initial Considerations

- 300mm Wafer Market Price
 - \$200/wafer
- 300mm Wafer Competitive Price
 - \$125/wafer
- For each plant option there are three scenarios
 - 1. 10,000 wafers/month
 - 2. 100,000 wafers/month
 - Initial production plan
 - 3. 500,000 wafers/month
 - Counter wafer expansion expectations (MEMC)

IRR Trends



Conclusions

- Main plant and alternate method economically feasible
- Batch Recharge is better option
- Primary Suggestion (500,000 wafer plant)
 - \$60 per Wafer (39% IRR)
- Secondary Suggestion (500,000 wafer plant)
 - \$100 per Wafer (55.8% IRR)

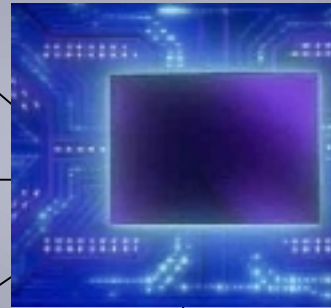
Acknowledgements

- Our Advisor – Dr. Talid Sinno
- CBE & MSE Departments
- Industrial Consultants
- The Aspen God: Professor Fabiano

Questions

Intro Supporting Slides

The Impact of Silicon Chips



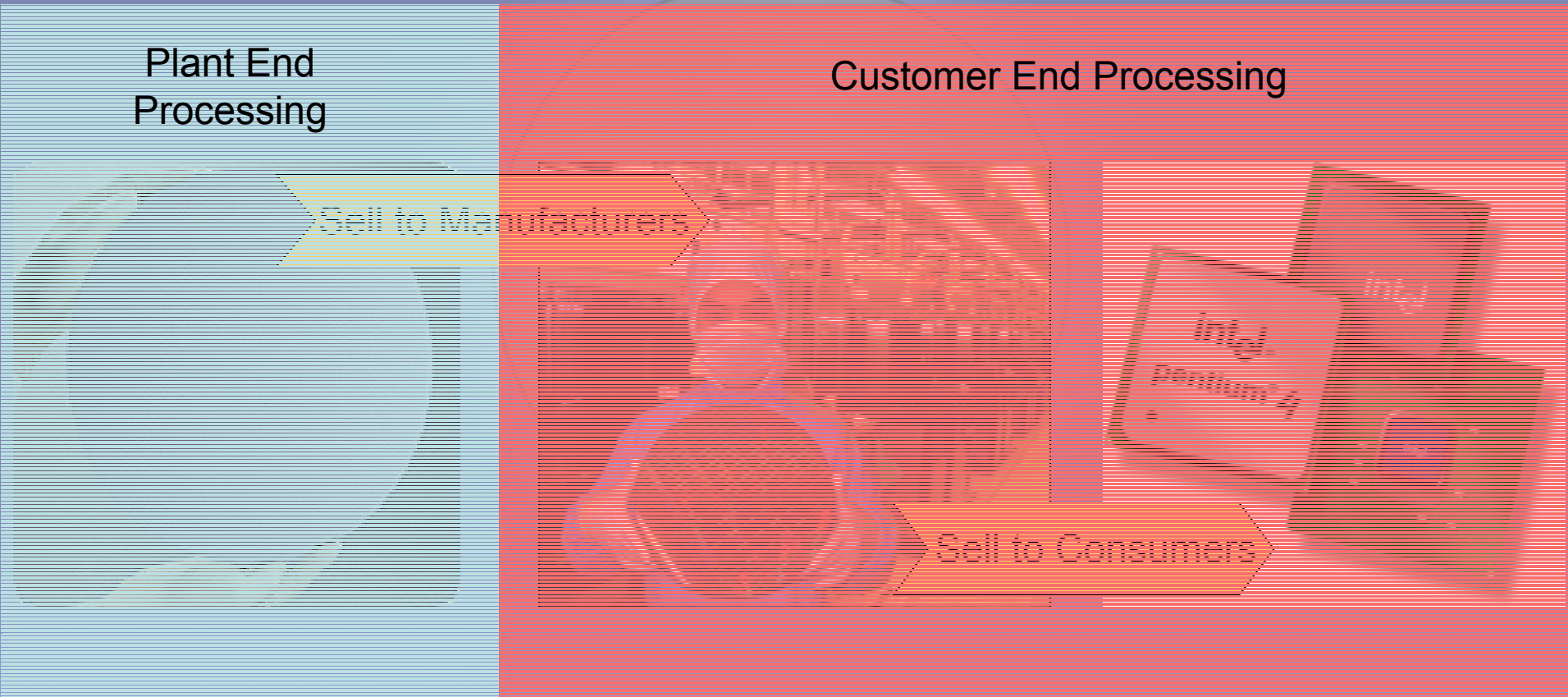
1 billion PCs sold worldwide by July, 2002



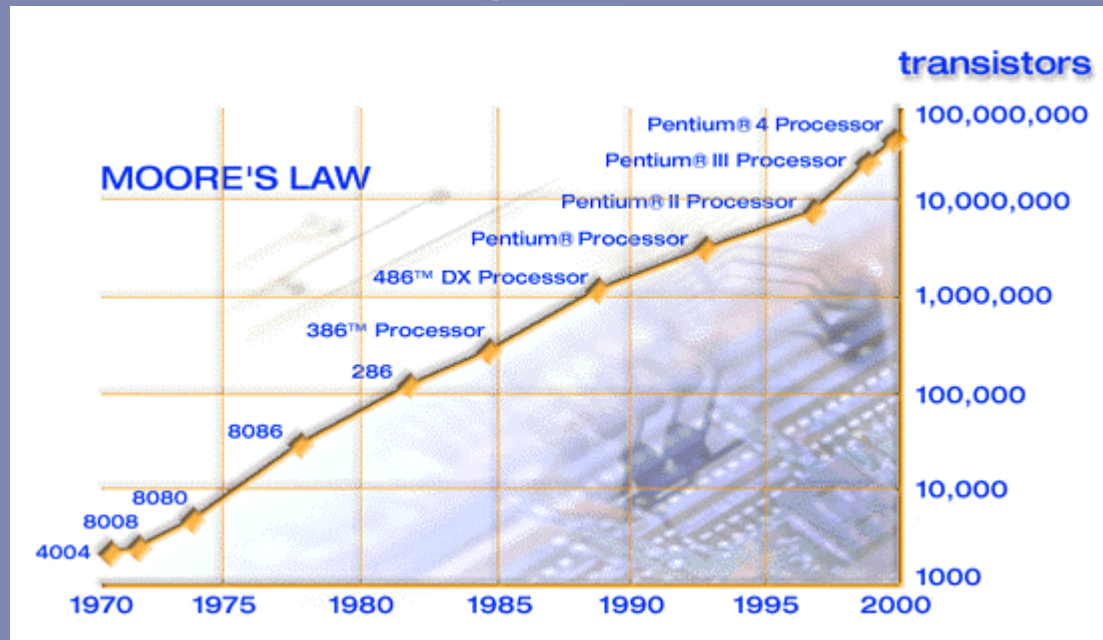
2 billion projected for 2008 (BBC)

What is a Silicon Wafer?

- Starting material for chip design



Silicon Purity: Moore's Law



- Number of transistors \sim processor speed
- Chip size is approximately constant
 - Transistor size must shrink
 - More control of material properties required = higher purity

The Si Wafer Market

- Only 5 major Si Wafer manufacturers
- Possible market entry?

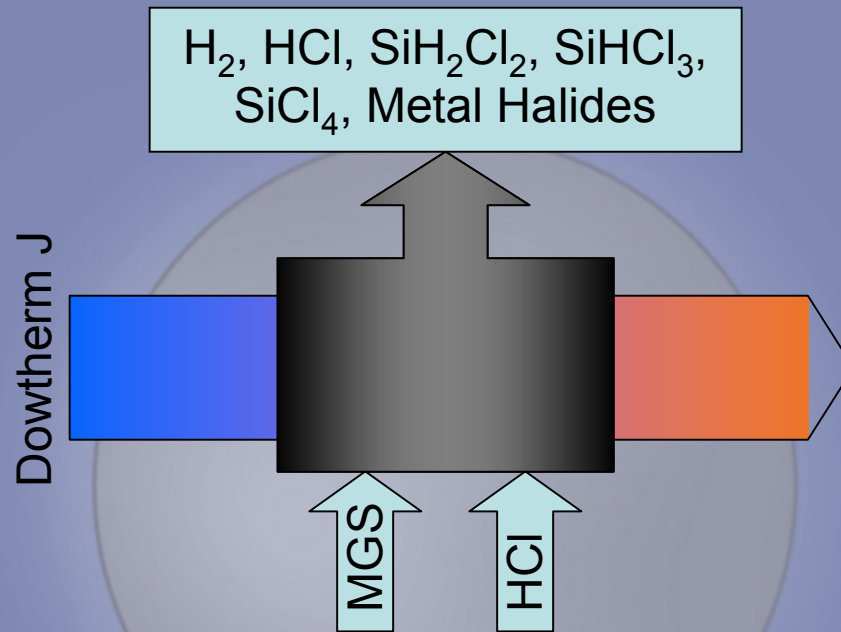


Cost Analysis Summary

	<u>10,000 wafer plant</u>			<u>100,000 Wafer Plant</u>			<u>500,000 Wafer Plant</u>		
Wafer Price (\$)	IRR	ROI	TCI	IRR	ROI	TCI	IRR	ROI	TCI
60	11.80%	13.50%	\$17.80	27.50%	37.10%	\$91	33.80%	60%	\$354.30
100	25.30%	30.50%	\$17.80	42.20%	72.50%	\$91	49.50%	93.60%	\$354.30
125	31.50%	41.10%	\$17.80	49.70%	93.20%	\$91	56%	120.30%	\$354.30
<u>Recharge Method</u>	IRR	ROI	TCI	IRR	ROI	TCI	IRR	ROI	TCI
60	0.10%	3.80%	\$22.50	36.00%	57.60%	\$71.80	39%	64.50%	\$296.80
100	17.50%	17.30%	\$22.50	51%	99.20%	\$71.80	55.80%	115.50%	\$296.80
125	24.70%	25.70%	\$22.50	58.80%	125.60%	\$71.80	65%	147%	\$296.80

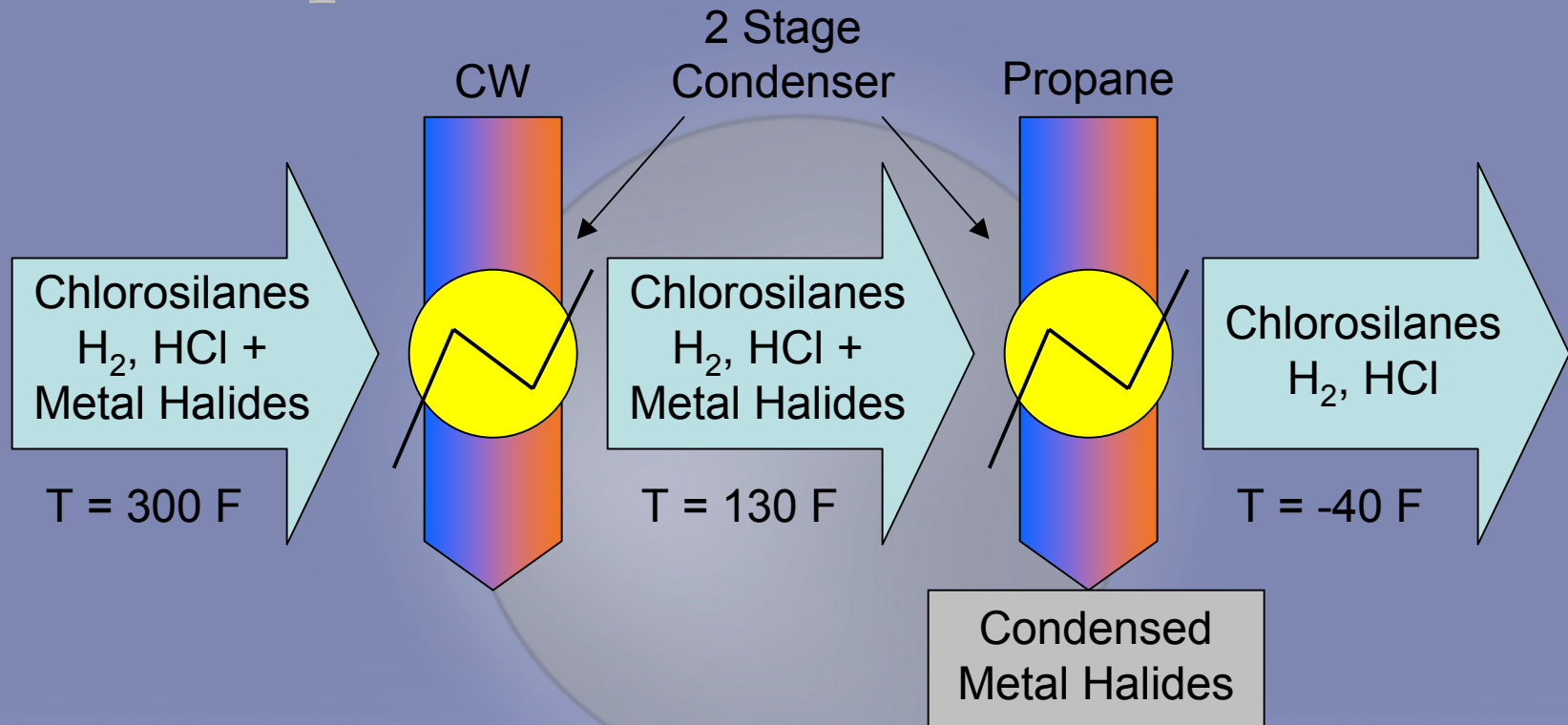
Process Supporting Slides

Initial Reaction: Fluidized Bed



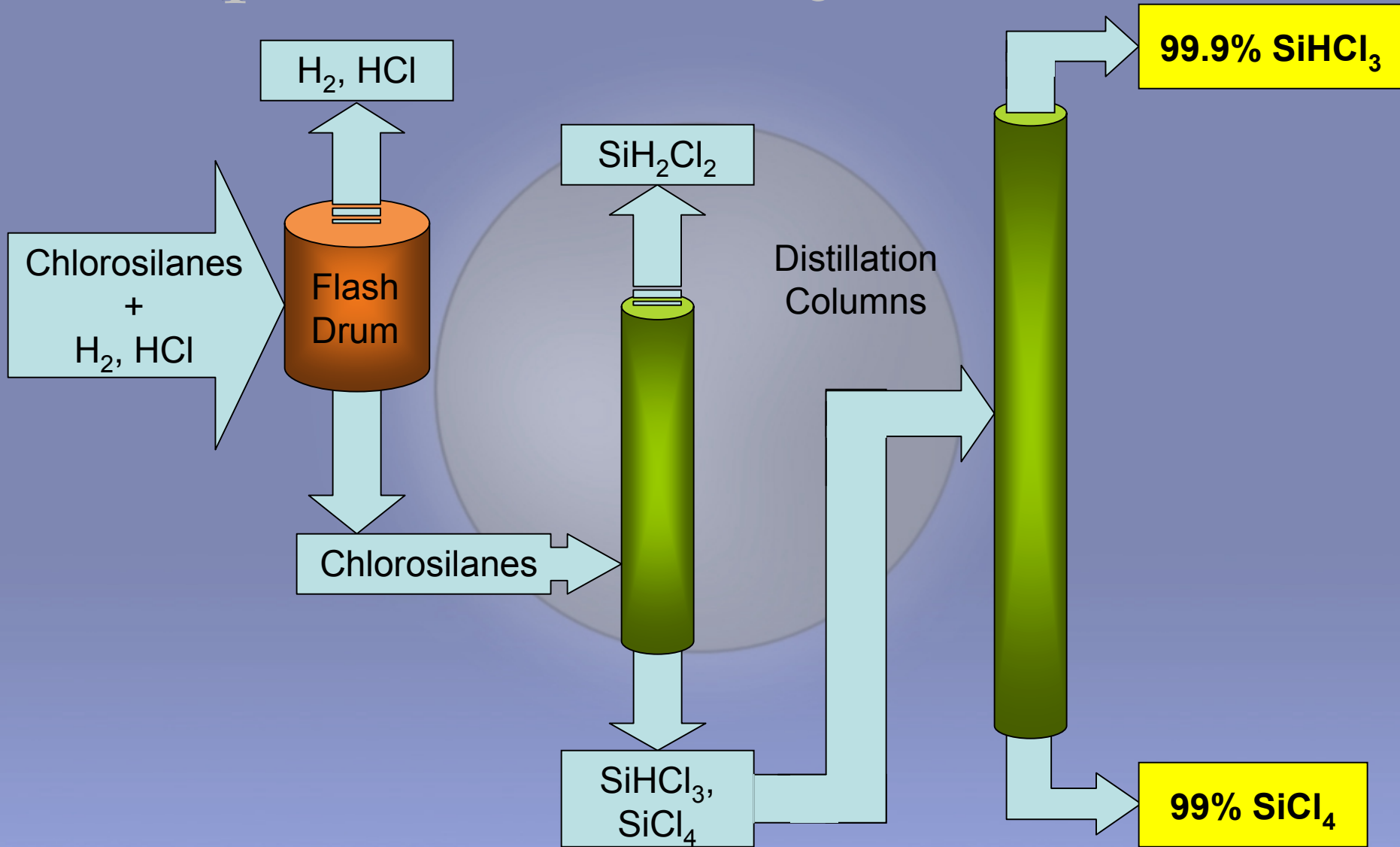
- Fluidized Bed is used due to high $\Delta H_{rxn} = -58.6$ kcal/mol $SiHCl_3$
- Cooling using a tube bundle inside of bed
 - Heat Transfer Fluid = Dowtherm J

Separations: Metal Halides



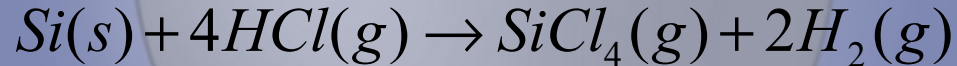
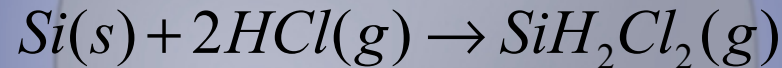
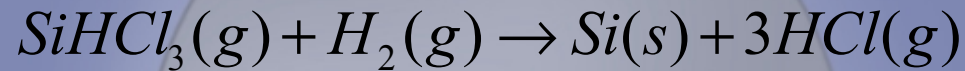
- Cleaning required
 - Infrequently because of low flow rate

Separations: SiHCl_3 Purification



Siemens Reactor Modeling

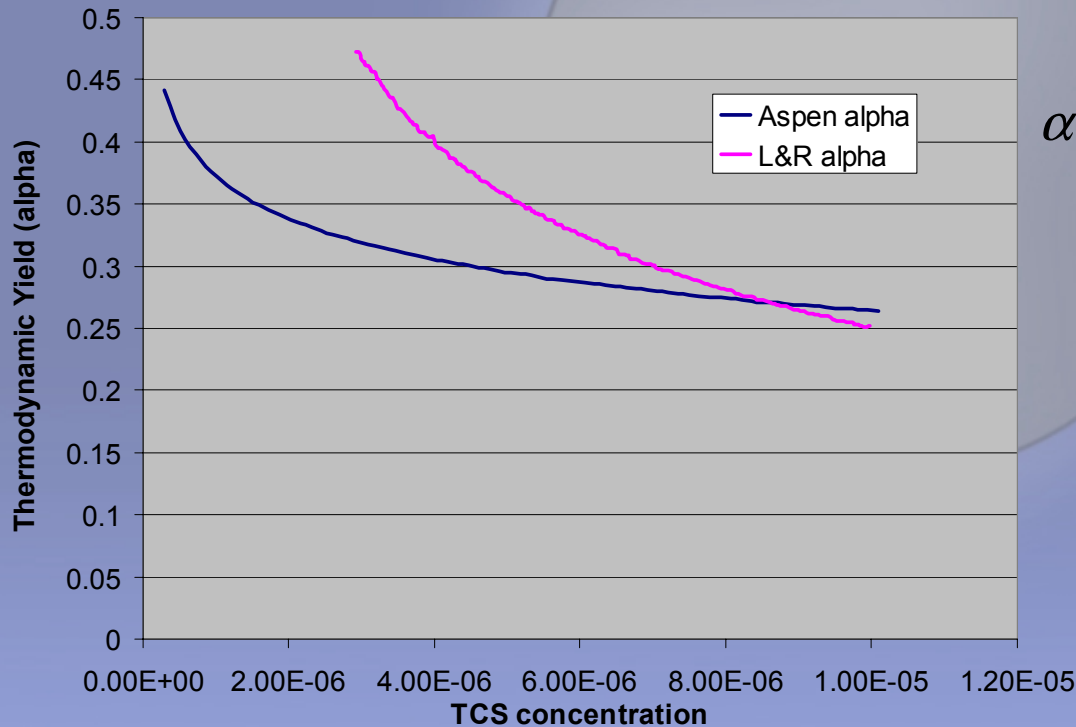
- Complex reaction:



- Trichlorosilane only reacts on rod
- Reaction rate constants not well known on rod

Thermodynamic Yield Study

- Laskafeld and Roznov prove that Siemens reactions go to equilibrium
 - Siemens reactor feed only contained SiHCl_3 and H_2



$$\alpha = \frac{(n_{\text{Si}}/n_{\text{Cl}})_{\text{entering}} - (n_{\text{Si}}/n_{\text{Cl}})_{\text{equilibrium}}}{(n_{\text{Si}}/n_{\text{Cl}})_{\text{entering}}}$$

**12 Siemens Reactors
Required**

Grow Single Crystal

- Requirements for single crystal grower:
 - Cooling rate must be very slow
 - Must be able to define wafer diameter well
 - Must not introduce impurities into system
- Czochralski crystal grower



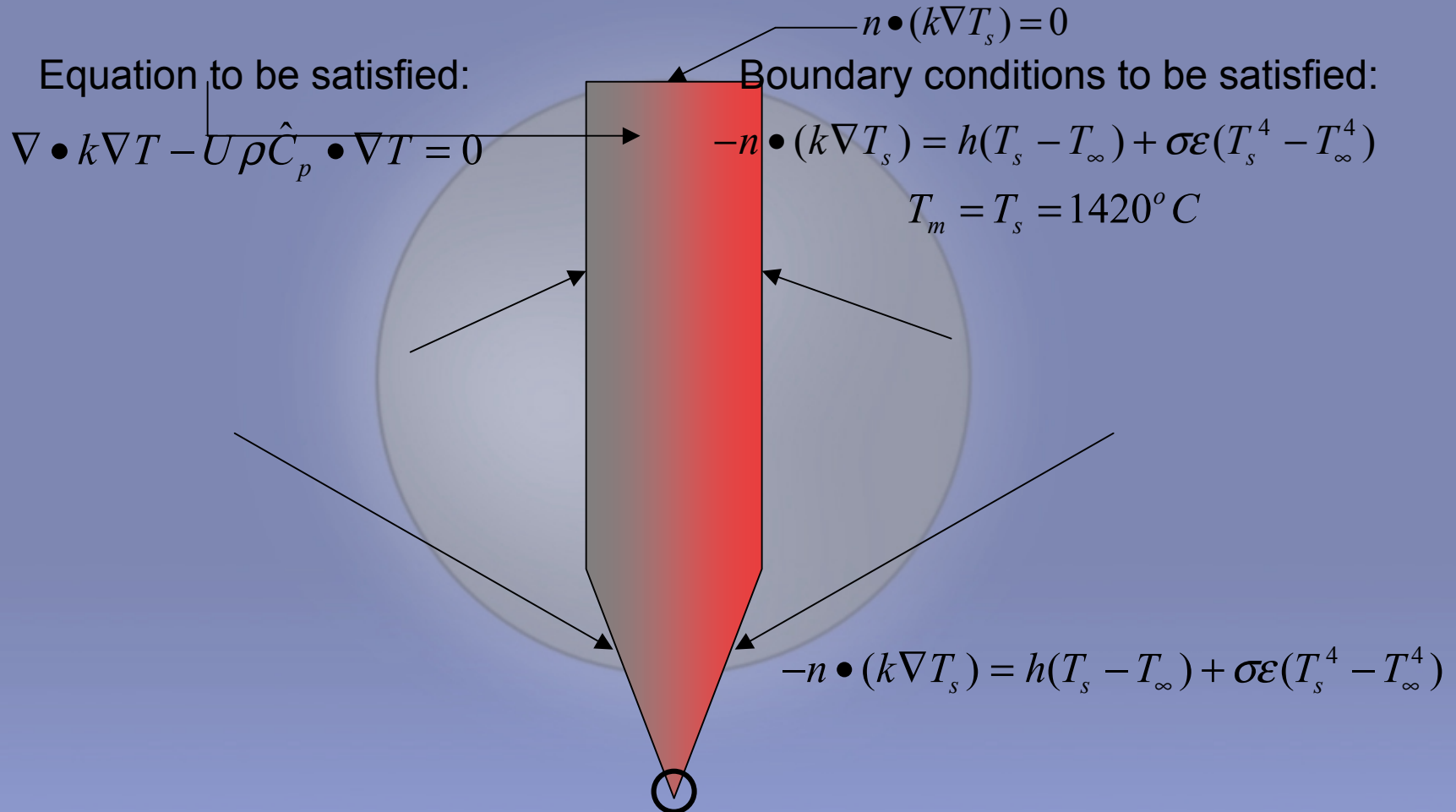
Determining Pull Rate

- MEMC uses 0.3 – 1.5 mm/min for 200mm wafers

$$R^{1/2} = \frac{C}{U}$$

- Our 300mm wafers will be pulled at 0.245 mm/min

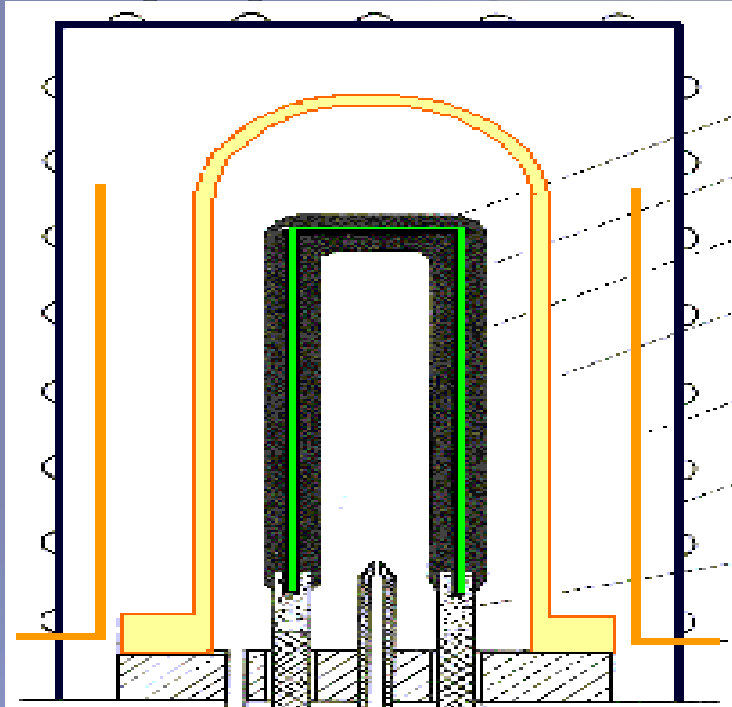
Determining End Cone Length



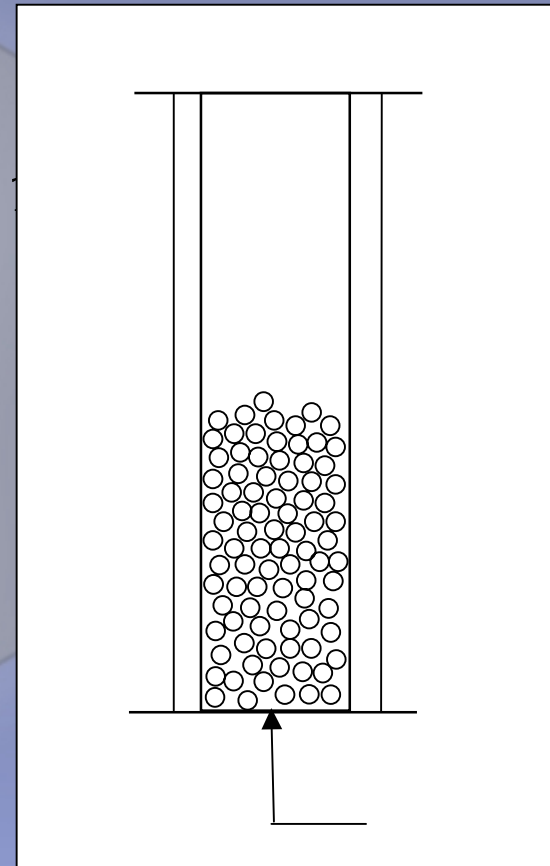
BRCz Supporting Slides

Silane vs. Trichlorosilane

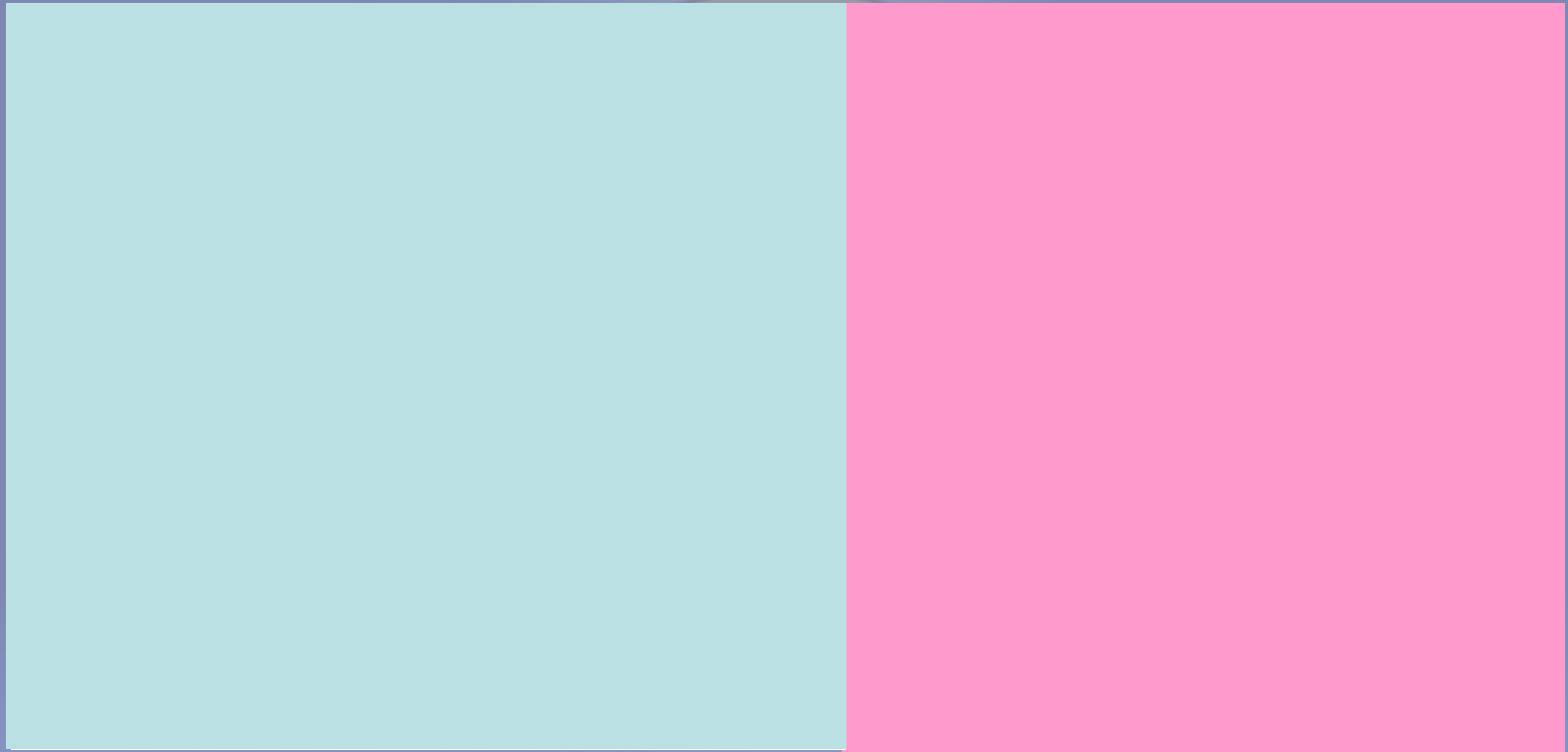
- Silane (SiH_4):
 - Cheap to produce



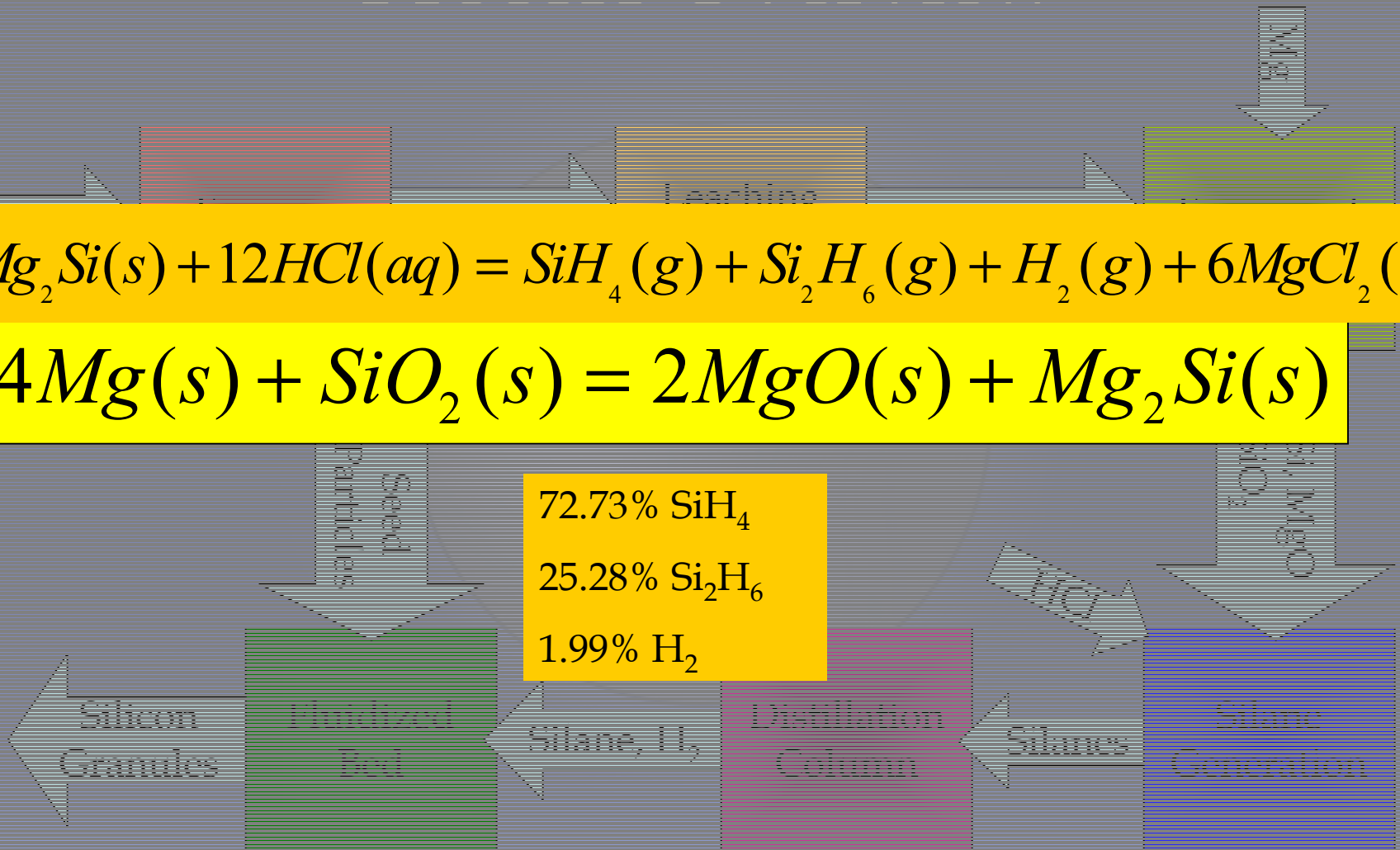
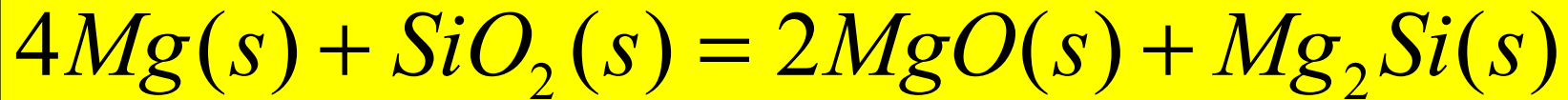
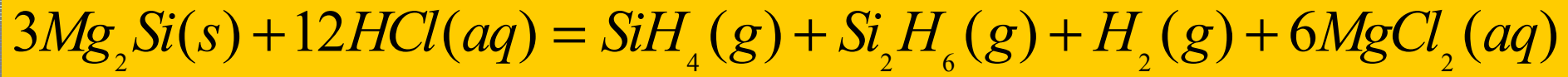
C vs.



Batch Recharging



Process Overview



Cost Analysis

- For a production rate of 100,000 wafers/month
 - Previous CTDC: \$84.3 million
 - New CTDC: \$72.6 million
 - Previous Operating Cost: \$2.83 million/yr
 - New Operating Cost: \$4.73 million/yr
 - Previous Utility Cost: \$14.85 million/yr
 - New Utility Cost: \$12.8 million/yr

Economic Analysis Supporting Slides

Economic Overview

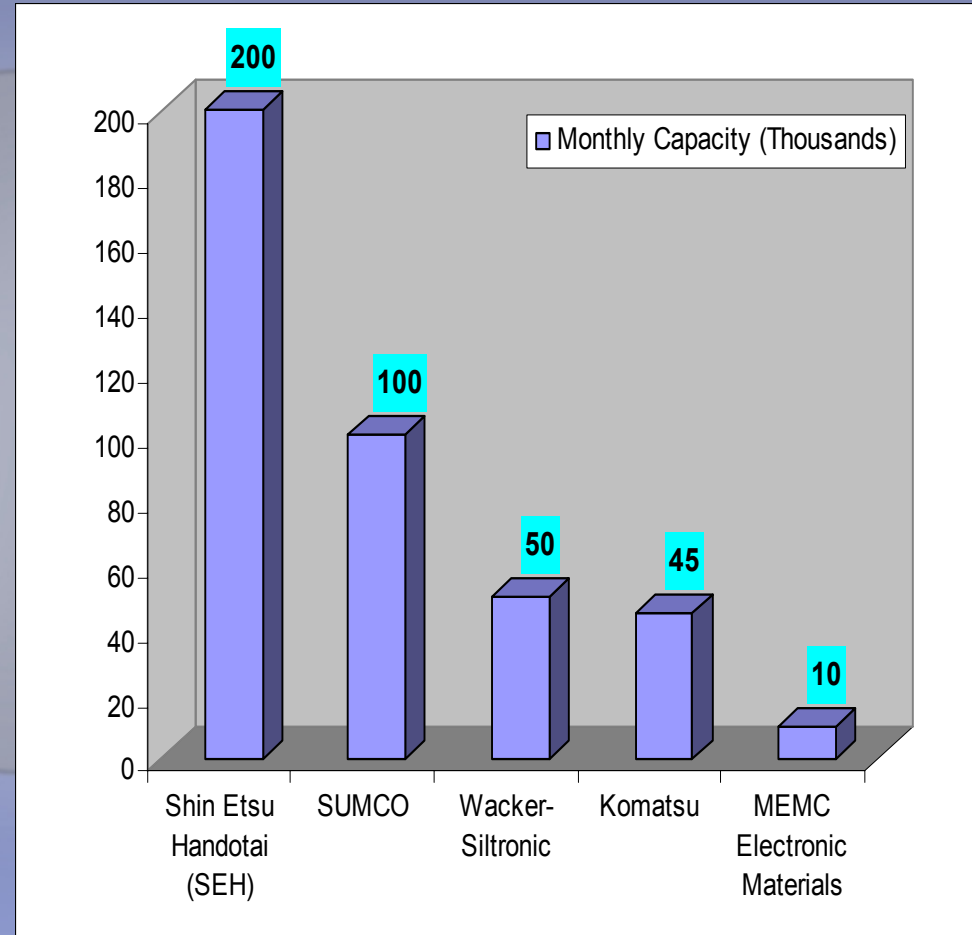
- The Big Players
- Market Trends
- Viability of Si Wafer Market
- Cost Analysis
 - Main Plant (Primary Process)
 - Overall plant (Including Batch Recharging Method)
 - Conclusions/Recommendations

Wafer Diameter: 200mm vs. 300mm

- 200 mm
 - High Current Demand
 - Higher Throughput
 - Low Selling Price (\$30/wafer)
- 300mm
 - Lower Current Demand
 - Lower Throughput
 - High Selling Price (\$200/wafer)
- Larger wafer = less manufacturing cost = **reduced cost for consumers**
 - Increasing Demand for 300mm wafers
 - Microprocessor companies currently transitioning between 200mm and 300mm technologies

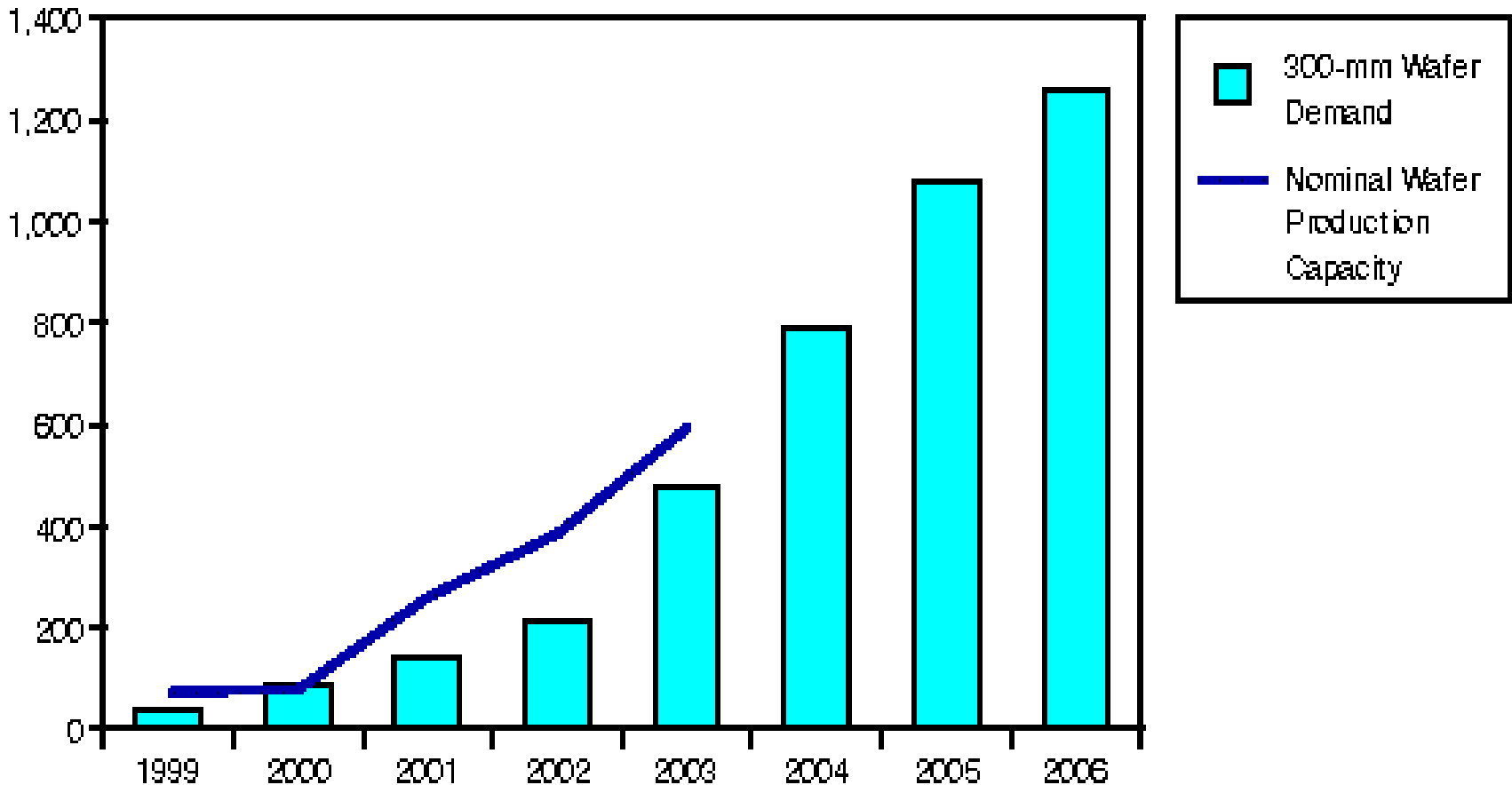
The Big Five

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- 90% of world's Si wafer producers
- Growing Competition => Merging Industries (SUMCO)



Market Wafer Demand Trend

Thousands of Units per Month



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Viability of Market

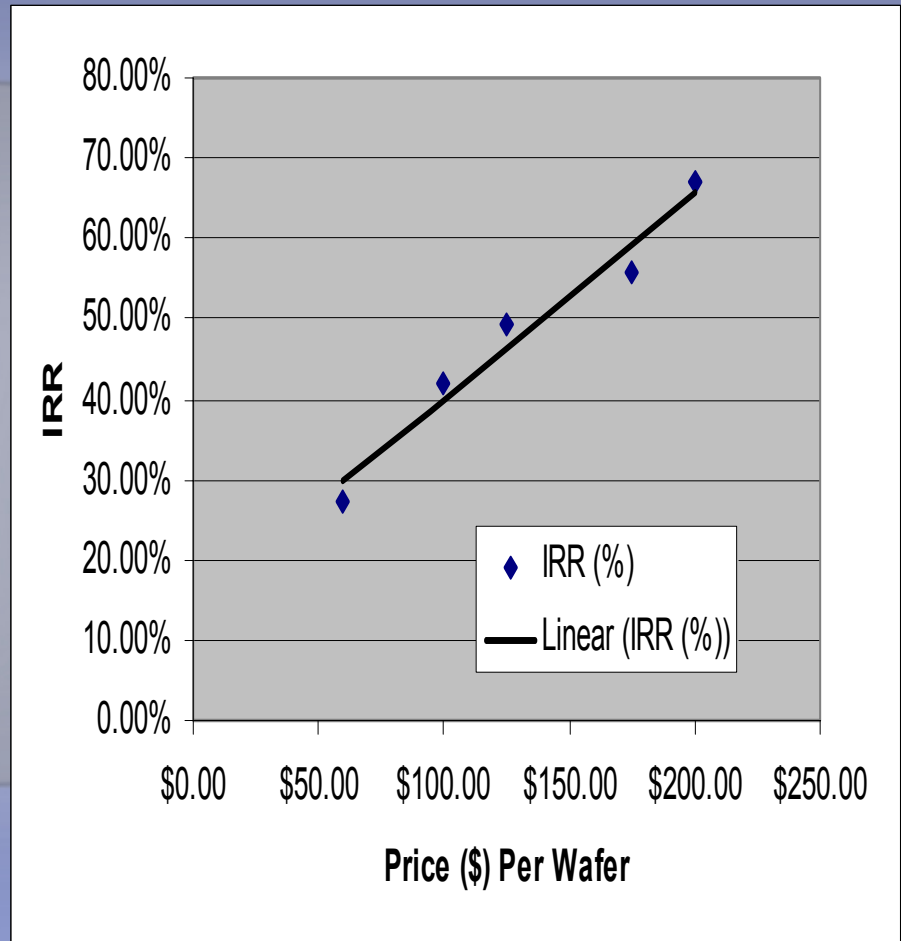
- Rising Global Chip sales
 - Global Chip Sales in August 2003: 13.4 billion\$
 - World-wide sales increase
 - Asia Pacific: 6.4%
 - Europe: 3.8%
 - Americas: 2.5 %
- Reason to enter Si wafer market
 1. Rising Sales → Higher Demand

Initial Considerations

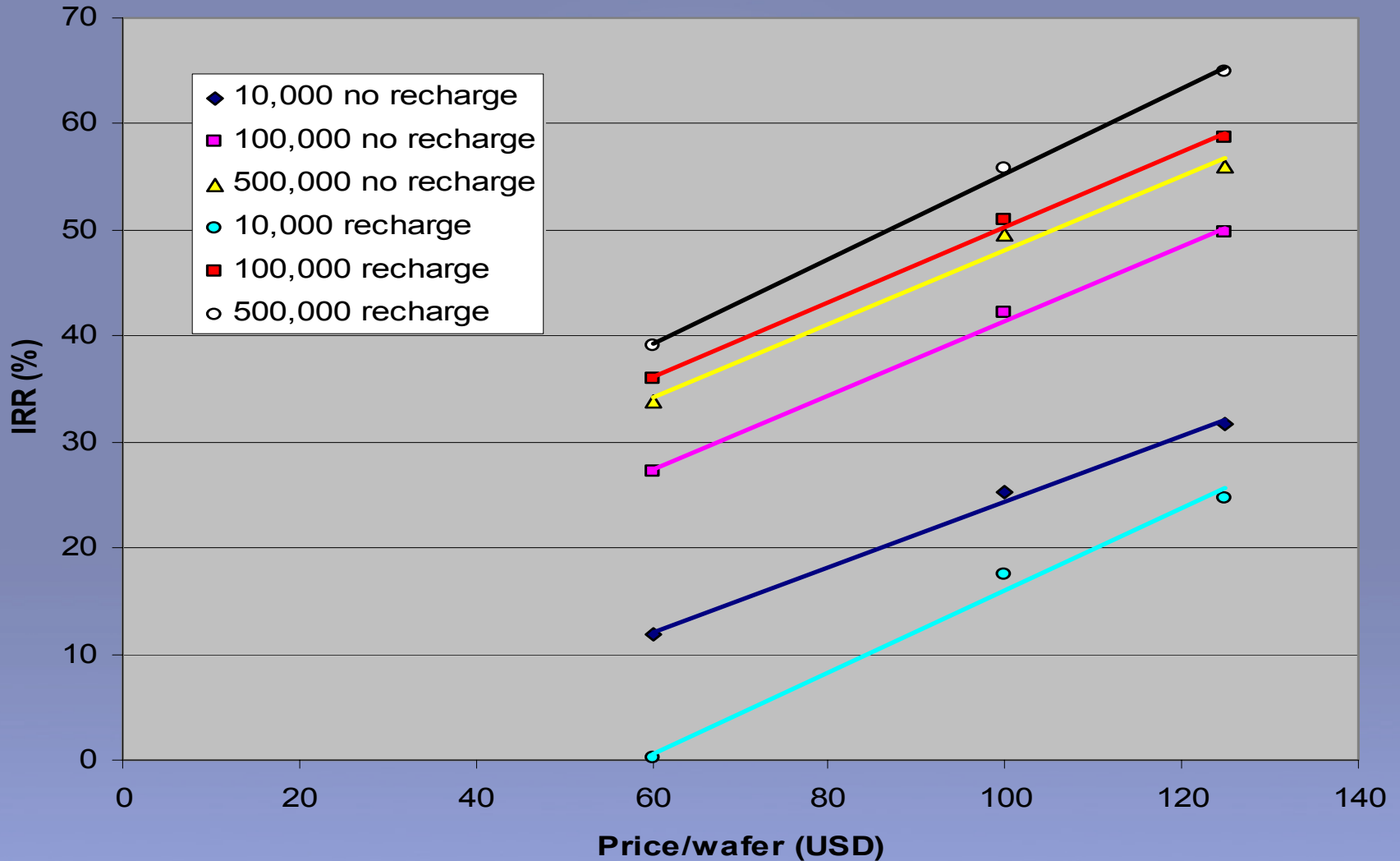
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Main Plant (100,000 wafer/mo)

- At Competitive price of \$125
 - IRR: 49.7%
 - ROI: 93.2%
 - Total Capital Investment: 91 million\$
- At Price of \$100
 - IRR: 42.2%
 - ROI: 72.5%
 - Total Capital Investment: 91 million\$



IRR Trends



A Further Explanation

- What you are thinking
 - Why the !@#\$ are the IRR values so high?
- The numbers
 - For the 100,000 wafer/mo plant
 - 26 Cz growers required
 - 2.7 mil\$ per grower → 70.2mil\$
 - Number of wafers per ingot: 839
 - Number of ingots per month: 128
 - 107,000 wafers → 10.7 mil\$/month (at 100\$/wafer)

Conclusions

- Main plant and alternate method economically feasible
- Batch Recharge is better option
- Primary Suggestion (500,000 wafer plant)
 - \$60 per Wafer
- Secondary Suggestion (500,000 wafer plant)
 - \$100 per Wafer

Recommendations

- Highly Volatile Market
 - 200mm wafer surfaced in 1984
 - 300mm wafer surfaced in 1991
 - Changing technologies
- Recommendation
 - Profitability analysis on projected shorter life plants (5, 8, 10 years)
 - Provides better prognosis to changing market